LISTING OF THE CLAIMS

Please amend claims 1 and 5, and add new claim 15 as indicated below. This listing of claims replaces all prior versions

- 1. (Currently amended) Method for operating an array of nonvolatile charge trapping memory devices, comprising:
- [[-]] before [[a]] block <u>erasing the array erase step of by discharging</u> substantially all of the non-volatile <u>charge trapping</u> memory devices of the array.

block programming the array by charging of substantially all of the non-volatile charge trapping memory devices of the array.

- 2. (Previously presented) Method according to claim 1, furthermore comprising after the erase operation programming some of the non-volatile memory devices of the array depending on data content to be stored in the non-volatile memory devices of the array.
- 3. (Previously presented) Method according to claim 2, furthermore comprising reading the data content stored in a non-volatile memory device of the array, wherein for reading the data content stored in a non-volatile memory device of the array at least one further non-volatile memory device having a dielectric charge trapping layer is used as reference cell which is programmed and erased for a block programming and block erase, respectively, of the non-volatile memory devices in the array.
- 4. (Previously presented) Method according to claim 3, wherein the memory devices of the array together function as reference cells.
- 5. (Currently amended) An electrical device comprising

an array of non-volatile charge trapping memory devices, eomprising:

- [[-]] means for block programming the array by charging of substantially all of the non-volatile charge trapping memory devices of the array,
- [[-]] means for block erasing the array by discharging of substantially all of the programmed non-volatile charge trapping memory devices of the array,

- [[-]] control means for controlling the array of non-volatile <u>charge trapping</u> memory devices such that before block erasing of substantially all of the non-volatile memory devices of the array, substantially all of the non-volatile memory devices of the array are block programmed.
- 6. (Previously presented) An electrical device according to claim 5, wherein the non-volatile memory device comprises a transistor having a channel and a control gate, a dielectric charge trapping layer being located between the channel and the control gate.
- 7. (Previously presented) An electrical device according to claim 5, the array being provided with at least one non-volatile memory device for use as a reference cell in a sense amplifier.
- 8. (Previously presented) An electrical device according to claim 7, the array comprising means for programming and erasing the reference cell for a block-programming and block-erasing respectively of the non-volatile memory devices in the array.
- 9. (Previously presented) An electrical device according to claim 7, wherein the at least one reference cell is separate from the array.
- 10. (Previously presented) An electrical device according to claim 7, wherein the memory devices of the array together function as reference cells.
- 11. (Previously presented)) An electrical device according to claim 7, comprising means for comparing a read current from a non-volatile memory device in the array with a read current from the reference cell.
- 12. (Previously presented) An electrical device according to claim 7, comprising means for adapting a read current for reading the non-volatile memory devices in the array to the ageing of the reference cell.

- 13. (Previously presented) An electrical device according to claim 7, comprising means for adapting a required control gate voltage for reading the non-volatile memory devices in the array depending on the ageing of the reference cell.
- 14. (Previously presented)) An electrical device according to claim 5, wherein the array of non-volatile memory devices forms a non-volatile memory.
- 15. (New) A method according to claim 1, wherein the non-volatile memory devices of the array each include a dielectric charge trapping layer and wherein block programming the array by charging substantially all of the non-volatile charge trapping memory devices of the array includes trapping charge in the dielectric charge trapping layers.